Nanopore Sequencing Technology and Tools: **Computational Analysis of the Current State, Bottlenecks and Future Directions** Damla Senol¹, Jeremie Kim^{1,3}, Saugata Ghose¹, Can Alkan² and Onur Mutlu^{3,1} ¹Carnegie Mellon University, Pittsburgh, PA, USA ² Bilkent University, Ankara, Turkey ³ ETH Zürich, Zürich, Switzerland







Genome Sequencing

Genome sequencing is the process of determining the order of the DNA sequence in an organism's genome.

Large DNA molecule



Long reads • Sequences with thousands of bases • Sequences with higher error rates • Suitable for **de novo assembly**

Long Read Analysis

De novo assembly is the method of • Merging the reads in order to construct the original sequence • Without the aid of a reference genome

sequencing is DNA emerging Nanopore an sequencing technology.

Nanopore Sequencing

SAFARI

- o Long read length
- Portable and low cost
- Produces data in real-time

Assembly quality can be improved by using longer reads, since they can cover long repetitive regions.

Nanopore sequencers solely the rely on electrochemical of different structure the nucleotides for identification and measure the change in the ionic current as long strands of DNA (ssDNA) pass through the nano-scale protein pores.

Pipeline and Current Tools



Problem & Our Goal

Problem

The tools used for nanopore sequence analysis are of critical importance in order to **increase the accuracy** of the whole pipeline to take better advantage of long reads, and increase the speed of the whole pipeline to enable real-time data analysis.

Our Goal

o Comprehensively analyze current publicly available tools in the whole pipeline for nanopore sequence analysis, with a focus on understanding their **advantages**, **disadvantages**, and **performance** bottlenecks.

• Provide guidelines for determining the appropriate tools for each step of the pipeline.

Results and Analysis

	Step 1Wall ClockTime (h:m:s)	Step 1 Memory Usage (GB)	Step 2Wall ClockTime (h:m:s)	Step 2 Memory Usage (GB)	Step 3 Wall Clock Time (h:m:s)	Step 3 Memory Usage (GB)	Number of Contigs	Identity (%)	Coverage (%)
Metrichor + Canu					44:12:31	5.76	1	98.04	99.31
Metrichor + Minimap + Miniasm			2:15	12.30	1:19	1.96	1	85.00	94.85
Metrichor + Graphmap + Miniasm			6:14	56.58	1:05	1.82	2	85.24	96.95
Nanonet + Canu	17:52:42	1.89			11:32:40	5.27	1	97.92	98.71
Nanonet + Minimap + Miniasm			1:13	9.45	33	0.69	1	85.50	93.72
Nanonet + Graphmap + Miniasm			3:18	29.16	32	0.65	1	85.36	92.05
Nanocall + Canu	47:04:53	37.73							
Nanocall + Minimap + Miniasm			1:15	12.19	20	0.47	5	80.53	96.80
Nanocall + Graphmap + Miniasm			5:14	56.78	16	0.30	3	80.52	95.43
Deepnano + Canu	23:54:34	8.38			1:15:48	3.61	106	92.63	154.07
Deepnano + Minimap + Miniasm			1:50	11.71	1:03	1.31	1	82.37	91.62
Deepnano + Graphmap + Miniasm		₹	5:18	54.64	58	1.10	1	82.39	91.60

OBSERVATION 1: Basecalling with **Recurrent Neural Networks** performs better than **basecalling with Hidden** Markov Models in terms of accuracy, speed, and memory usage. However, it has scalability limitations due to **data** sharing between threads.

eak Me Usage 05 **OBSERVATION 2:** Sharing the computation of a read between parallel threads provides a constant and **low** memory usage, but data sharing between multiple sockets **degrades the** parallel speedup when number of threads reaches higher values.



OBSERVATION 3: Storing **minimizers** instead of all k-mers does not affect the accuracy of the whole pipeline. However, Minimap has a lower memory usage and higher speed than GraphMap, since computation is decreased by shrinking the size of the dataset that needs to be considered.

OBSERVATION 4: Canu, an assembler with error correction, produces **high-quality assemblies** but is **slow** compared to Miniasm, an assembler without error correction. Miniasm is suitable for **fast initial analysis**, and the quality of its assembly can be increased with an additional polishing step. **5**: Nanopolish is compatible **OBSERVATION** only with reads basecalled by Metrichor.

Polishing the draft assembly generated with Canu takes **5h52m** and increases the accuracy from 98.04% to 99.46%.

Polishing the draft assembly generated with Miniasm takes **5d2h54m** and increases the accuracy from 85.00% to 92.31%.